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FABRICATION OF SENSITIVE HIGH T_c BOLOMETERS*

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The rapid change of resistance with temperature of high quality films of high T_{c} superconductors can be used to make resistance thermometers with very low temperature noise. Measurements on c-axis YBCO films have given a spectral intensity of temperature noise less than $4x10^{-8}$ K/Hz^{1/2} at 10 Hz. Consequently, the opportunity exists to make useful bolometric infrared detectors that operate near 90 K which can be cooled with liquid nitrogen. This talk will summarize the fabrication and measurement of two bolometer architectures. The first is a conventional bolometer which consists of a 3000 Å thick YBCO film deposited in situ by laser ablation on top of a 500 Å thick SrTiO₃ buffer layer on a {1012} $A\hat{l}_2O_3$ substrate. The sample was lapped to 20 μm thickness and diced into 1x1 mm² bolometer chips. Gold black smoke was used as the radiation absorber. The voltage noise was less than the amplifier noise when the film was current biased. Optical measurements gave an NEP of $5x10^{-11}$ W/Hz^{1/2} at 10 Hz. The second architecture is that of an antenna-coupled microbolometer which consists of a small ($5x10 \mu m^2$) YBCO film deposited directly on a bulk substrate with a low thermal conductance (YSZ) and an impedance matched planar lithographed spiral or log-periodic antenna. This structure is produced by standard photolithographic techniques. Measurements gave an electrical NEP of 4.7×10^{-12} W/Hz^{1/2} at 10 kHz. Measurements of the optical efficiency are in progress. The measured performance of both bolometers will be compared to other detectors operating at or above liquid nitrogen temperatures so as to identify potential applications.

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Fabrication of Sensitive High Tc Bolometers

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Outline

- Motivation and applications
- Conventional composite bolometer
- Microbolometer
- Conclusions

High background applications

Performance ($D^* = AREA^{1/2}/NEP$) of commercial photon detectors viewing 300K source.



Performance available at or above 77K



Applications above 77K:

- Laboratory IR spectrometers
- Earth observations from space



P. L. Richards et al, Appl. Phys. Lett. 54, 283 (1989).

Elements of high T_c infrared bolometers

	Conventional Bolometer	<u>Microbolometer</u>
Substrate	sapphire	yttria stabilized zirconia (YSZ)
Radiation absorber	gold black Bi film	antenna-coupled YBCO
Thermometer R(T)	YBCO	YBCO
Thermal conductance G	Cu leads	thermal spreading resistance
Cu YBCO Heater Al ₂ O ₃	ermometer	Bolometer Bow-Tie Antenna

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The high Tc conventional bolometer

- Easy to make one that "works".
- Hard to get useful sensitivity.
- Good ones can be made now.
- Materials needs very specific.
- Low-noise and high $\frac{1}{R} \frac{dR}{dT}$.
- Proper optimization.

Fabrication

- Substrate $1 \times 1 \text{ mm}^2$, $20 \,\mu\text{m}$ thick, { $1\overline{1}02$ } sapphire.
 - Low specific heat
 - Strong
 - YBCO compatible
 - Laser ablate 3000 Å YBCO on a 500 Å SrTiO₃ buffer layer on $6\times6\times0.5$ mm³ sapphire.
- Sputter clean YBCO surface and sputter deposit Ag electrical contacts.
- Polish and dice.

Sensitivity \Rightarrow YBCO film quality

high $\frac{1}{R}\frac{dR}{dT}$, low noise

- Laser ablating YBCO on sapphire gives sharp resistive transitions (K. Char et al, Appl. Phys. Lett., 56. 785 (1990)).
- But there is excess voltage noise near T_c under current bias in these films.



Using the 500Å SrTiO₃ buffer layer \Rightarrow reduced voltage noise.



Bolometer optimization

Given:
$$\frac{1}{R} \frac{dR}{dT}$$
C -- heat capacityPick:I--current biasR--operating resistanceG--thermal conductance ω --chopping frequency

NEP =
$$\begin{pmatrix} 4kTR + V_{amp}^2 + V_{1/f}^2 \\ 4kT^2G + \frac{|S|^2}{|S|^2} \end{pmatrix}^{1/2}$$

 $S = I \frac{dR(T)}{dT} |G + i\omega C|^{-1} , \qquad I^2 R < 0.3 G \delta T \quad \text{for stability} .$ $\delta T -- \text{ transition width}$

For a sapphire bolometer:

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$$ω/2π = 10 \text{ Hz}$$
 1×1×0.02 mm³ sapphire
 $δT = 0.5 \text{ K}$ NEP $\le 10^{-11} \text{ W/Hz}^{1/2}$

Measurements



Typical Size 1×1 mm

- R(T) and load curve \Rightarrow S_{electrical} = 26 V/W , 10 Hz
- Chopped He-Ne laser \Rightarrow S_{optical} = 22 V/W , 10 Hz
- At present, noise is \Rightarrow NEP = 5×10⁻¹¹ W/Hz^{1/2}, 10 Hz amplifier limited

Electrical measurements



Bolometer R(T)

Optical response





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High T_c Microbolometer

Sensitive and fast

- Small area (A \approx 5 μ m²)
- Deposited directly on thick substrate
- Only small volume of substrate contributes thermally $(V \approx 10 \ \mu m^3)$
- NEP α A^{1/4}
- Response time α A
- Couple directly $\lambda < 2 \,\mu m$
- Couple with antenna $\lambda > 100 \,\mu\text{m}$
- Array compatible fabrication

Qing Hu and P. L. Richards, Appl. Phys. Lett. 55, 2444 (1989).

Idea from: Hwang, Schwarz, Rutledge Neikirk, Lam, Rutledge Rutledge, Neikirk, Kasilingam

Microbolometer thermal response



How to couple long wavelengths into a small bolometer?

- Antenna-coupled microbolometer
- Self complementary planar antenna
 - Real antenna impedance
 - Broadband response $\lambda > 100 \,\mu\text{m}$
- Single mode throughput $A\Omega = \lambda^2$



Log-Periodic Antenna

Spiral Antenna

Fabrication of microbolometer

- Single target sputtered 3000 Å YBCO on YSZ.
- Pattern YBCO into 5 μ m wide strips in acid etch.
- Sputter clean YBCO surface and sputter deposit Ag.
- Wet etch Ag antenna pattern.
- Oxygen anneal 500° C for 1 hr.



Electrical NEP of microbolometer

T=88.3 K, f=10 kHz



- Electrical NEP is G-noise limited.
- $R = 6\Omega \implies$ transformer coupled.
- Optical efficiency measurements in progress.



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Conclusions

- High T_c bolometers have a future for applications where cooling is limited.
- Best opportunities are for $\lambda \ge 15 \ \mu m$.
- Require highest materials quality on the "right" substrates.
- We have made conventional bolometers and microbolometers with performance approaching theoretical predictions.